PATENT ASSIGNMENT

Electronic Version v1.1 Stylesheet Version v1.1

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	EXECUTIVE ORDER 9424, CONFIRMATORY LICENCE

CONVEYING PARTY DATA

Name	Execution Date
Northwestern University	03/08/2006

RECEIVING PARTY DATA

Name:	National Science Foundation
Street Address:	4201 Wilson Blvd.
Internal Address:	rm 1265
City:	Arlington
State/Country:	VIRGINIA
Postal Code:	22230

PROPERTY NUMBERS Total: 1

Property Type	Number
Application Number:	11316550

CORRESPONDENCE DATA

Fax Number: (703)292-9041

Correspondence will be sent via US Mail when the fax attempt is unsuccessful.

Phone: 703-292-8060

Email: sbattle@nsf.gov

Correspondent Name: Robin C. Fritsch

Address Line 1: 4201 Wilson Blvd.

Address Line 2: rm 1265

Address Line 4: Arlington, VIRGINIA 22230

NAME OF SUBMITTER: R. Fritsch

Total Attachments: 3

source=Conf_lic60004#page1.tif source=Conf_lic60004#page2.tif source=Conf_lic60004#page3.tif

> PATENT REEL: 017743 FRAME: 0636

License to the United States Government

(Business Address)

Sign and Fax this to (301) 480-0272
Invention Title: p-type Iransparent Conducting Oxides And Methods For Preparation
Inventor(s): Thomas Mason, Kenneth Poeppelmeier, Dean Shahriari, Antonine Barnabe
U.S. Filing/Issue Date: 12/22/05
Patent or Application Serial No.: 11/316,550
Grant/Contract Number(s): DMR 9632472, AAD-9-18668-05
Foreign Applications filed/intended in (countries):
The invention identified above is a Subject Invention under 35 U.S.C. 200, et seq. , and the Standard Patent Rights clause at 37 CFR 401.14, FAR 52.227-11 or FAR 52.227-12 (if applicable) which are included among the terms of the above identified grant or contract award from the United State Government. This document is confirmatory of:
 The nonexclusive, nontransferable, irrevocable, paid-up license to practice or have practiced for or on behalf of the United States the invention described in any patent application and in any and all divisions, continuations, and continuations in part, and in any and all patents and re-issues granted thereon throughout the world; and All other rights acquired by the Government by reason of the above identified grant/contract award and the laws and regulations that are applicable to the award.
The Government is hereby granted an irrevocable power to inspect and make copies of the above-identified patent application.
Signed this 8th day of March , 20 06 By Indrani Mukharji, PhD Indrani Mukharji (Signature) (Signature)
By Indrani Mukharji, PhD Indrani Mukharji
(Name of Grantee/Contractor Official) (Signature)
Title Executive Director
For Northwestern University, Technology Transfer Program
(Grantee/Contractor Organization)
At Sherman Avenue - Suite 504
Program Coordinator (847)491-3005

PATENT REEL: 017743 FRAME: 0637 p-TYPE TRANSPARENT CONDUCTING OXIDES AND METHODS FOR PREPARATION

Background of the Invention.

This application claims priority benefit from provisional application serial number

60/281,211 filed on April 3, 2001, the entirety of which is incorporated herein by

reference.

The United States Government has certain rights to this invention pursuant to

Grant No AAD-9-18668-05 from the Department of Energy and Grant No.

DMR-0076097 from the National Science Foundation, both to Northwestern University.

This invention relates generally to transparent conducting oxides, and more

particularly, to such compositions and related structures having p-type conductivities and

methods for their preparation under hydrothermal reaction conditions

Transparent conducting oxides (TCOs) are degenerate wide band-gap

semiconductors with conductivities comparable to metals, but are transparent over the

visible and IR regions. Currently, the best known and industrially useful TCOs are doped

ZnO, SnO₂ and In₂O₃, all of which are n-type semiconductors For example, in thin film

forms, Sn-doped indium oxide has n-type conductivity on the order of 103 S/cm and an

average transmittance higher than 85% in the visible light range By comparison, in thin

film form, the p-type conductivity of CuAlO₂ is about 1 S/cm and about 10⁻³ S/cm in bulk

form (H. Kawazoe, M. Yasukawa, H. Hyodo, M. Kurita, H. Yanagi and H. Hosono,

Nature, 389, 939-942 (1997) p-Type Electrical Conduction in Transparent Thin Films of

MW\720975RDD:SW 04/03/02

PATENT REEL: 017743 FRAME: 0638

RECORDED: 06/08/2006